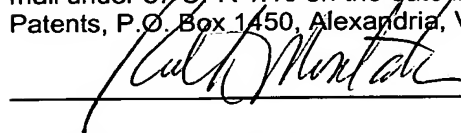


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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Attorney's Docket No.: GK-OEH-191/500814.20093

U.S. Application No.: 10/521,088

International Application No.: PCT/DE2003/002359

International Filing Date: JULY 10, 2003

10 JULY 2003

Priority Date Claimed: JULY 12, 2002

12 JULY 2002

Title of Invention: PULSE LASER ARRANGEMENT AND METHOD FOR SETTING PULSE LENGTH FOR LASER PULSES

Applicant(s) for (DO/EO/US): Guenter HOLLEMANN, Martin LEITNER and Jan SYMANOWSKI

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Alexandria, VA 22313-450

**SUPPLEMENTAL  
INFORMATION DISCLOSURE STATEMENT**

S I R:

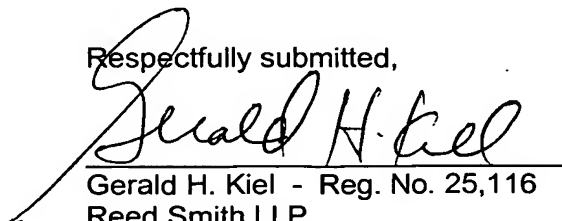
Supplemental to the information Disclosure Statement filed on January 12, 2005, applicants submits a copy of article AX previously omitted and a Supplemental PTO-1449.

OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

**AX R. Iffländer, Solid state Lasers for Materials Processing, Springer Series in Optical Sciences, Springer Verlag, Berlin (2001), pages 28-32**

This submission is not an admission that the information disclosed in the documents is material to the patentability of the invention disclosed and/or claimed in the above-identified application.

Respectfully submitted,



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Enclosures:  
Suppl PTO-1449 and article;

**SUPPLEMENTA'**  
**LIST OF PRIOR ART CITED BY APPLICANT**  
 (Filed on September 23, , 2005)

Docket No. GK-OEH-191/500814.20093

Applicant(s): Guenter HOLLEMANN, Martin LEITNER and Jan SYMANOWSKI

Application No. 10/521,088 (Int'l Appln No. PCT/DE2003/002359 10JUL03) Group:

Filed: Examiner:

**U.S. PATENT DOCUMENTS**

Exam. Init		Document Number	Date	Name	Class	Sub-Class	Filing Date Appropriate
	AA	4,725,787	02/16/1998	Chandra			
	AB	4,896,119	01/23/1990	Williamson, et al.			
	AC	5,867,324	02/02/1999	Kmetec, et al.			
	AD	5,907,570	05/25/1999	Nighan, et al.			
	AE	6,122,097	09/19/2000	Weston, et al.			
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

**FOREIGN PATENT DOCUMENTS**

		Document Number	Date	Country	CLASS	Sub-Class	Translation	
							YES	NO
	AL	1 308 384	02/28/1973	Great Britain				
	AM	0 609 978	08/10/1994	European				
	AN	WO 96/16484	05/30/1996	WIPO				
	AO	199 27 918	12/21/2000	Germany			Abstract only	
	AP	199 58 566	06/07/2001	Germany			Abstract only	
	AQ	2 357 369	06/20/2001	Great Britain				
	AR	100 43 269	04/04/2002	Germany			Abstract only	
	AS	100 63 976	07/04/2002	Germany			Abstract only	
	AT							

**OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)**

AX	R. Iffländer, Solid state Lasers for Materials Processing, Springer Series in Optical Sciences, Springer Verlag, Berlin (2001) pages 28-32
AY	
AZ	

Examiner:

Date:

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

NOTE: Strikethrough documents were submitted on January 12, 2005